Exploring the microstructure and mechanical properties of TiZrNbTaMoN high entropy alloy nitride coating: Effect of nitrogen content

Sen-You Hou¹, Po-Yu Chen^{1,2}, Bih-Show Lou^{3,4}*, Jyh-Wei Lee^{2, 5, 6, 7}

¹Department of Materials Science and Engineering, National Tsing Hua University, Hsinchu, Taiwan ²High Entropy Materials Center, National Tsing Hua University, Hsinchu, Taiwan ³Chemistry Division, Center for General Education, Chang Gung University, Taoyuan, Taiwan

⁴Department of Orthopaedic Surgery, New Taipei Municipal TuCheng Hospital, Chang Gung Memorial

Hospital, Taiwan

⁵Department of Materials Engineering, Ming Chi University of Technology, New Taipei City, Taiwan ⁶Center for Plasma and Thin Film Technologies, Ming Chi University of Technology, New Taipei,

Taiwan

⁷Colleage of Engineering, Chang Gung University, Taoyuan, Taiwan

The high power impulse magnetron sputtering (HiPIMS) generates high density plasma through higher instantaneous pulse currents, resulting in thin films with fewer defects, higher density, and denser microstructure. In this work, a combination of HiPIMS and radio frequency power supply system was used to deposit TiZrNbTaMoN high entropy alloy (HEA) thin films with varying nitrogen contents on Si wafer, AISI304 and 420 stainless steel substrates. The cross-sectional morphology, composition, and crystal structure of thin films were analyzed using scanning electron microscopy, electron probe microanalyzer, X-ray diffraction, and transmission electron microscope, respectively. Subsequently, potentiodynamic polarization corrosion tests were conducted on the HEA thin films in 3.5 wt.% NaCl aqueous solution using an electrochemical workstation to evaluate their corrosion resistance. We found that TiZrNbTaMoN HEA nitride coatings exhibited a hardness of up to 29 GPa, along with outstanding corrosion resistance. The effect of nitrogen content on the phase, mechanical properties, and corrosion resistance of TiZrNbTaMoN HEA thin films was discussed in this work. The potential applications for the TiZrNbTaMoN HEA thin films in the machining industries were proposed.

Key Words: high power impulse magnetron sputtering, TiZrNbTaMoN high entropy alloy nitride coating, corrosion resistance, hardness.